## 2025년 2월 12일(수)-14일(금) | 강원도 하이원리조트

## Future Normal in Semiconductor

2025년 2월 13일(목), 15:50-17:20 Room K(하트 I), 6층

#### J. Nano-Science & Technology 분과

### O37\_[TK3-J] Emerging Nanomaterials & Applications

#### 좌장: 김철주 교수(POSTECH). 강기훈 교수(서울대학교)

	작성: 검열수 포우(PUSTEUR), 경기운 포우(지울대학포)
TK3-J-1 15:50-16:05	Mitigating Substrate Effects of van der Waals Semiconductors using
	Perfluoropolyether Self-Assembled Monolayers
	Dae Young Park <sup>1</sup> , Hyeong Chan Suh <sup>1</sup> , Seungho Bang <sup>1</sup> , Ju Chan Lee <sup>2</sup> , Jaekak Yoo <sup>1</sup> ,
	Hayoung Ko <sup>2</sup> , Soo Ho Choi <sup>2</sup> , Ki Kang Kim <sup>2</sup> , Seung Mi Lee <sup>3</sup> , Seong Chu Lim <sup>2</sup> , Tschang
	Uh Nahm <sup>1</sup> , and Mun Seok Jeong <sup>1</sup>
	<sup>1</sup> Department of Physics, Hanyang University, <sup>2</sup> Department of Energy Science,
	Sungkyunkwan University, <sup>3</sup> KRISS
TV2 I 2	Facile Repairing Process of Sulfur Vacancy on MoS2 Surface with
	Fluorinated Benzenethiol
TK3-J-2	Mingyu Kim <sup>1</sup> , Haksoon Jung <sup>1</sup> , Yongwoo Lee <sup>2</sup> , Taoyu Zou <sup>1</sup> , Jimin Kwon <sup>2</sup> , and Yong-
16:05-16:20	Young Noh <sup>1</sup>
	<sup>1</sup> Department of Chemical Engineering, POSTECH, <sup>2</sup> Department of Electrical Engineering, UNIST
TK3-J-3 16:20-16:35	Exploring the Piezoresistive Pressure Sensing Range in MOCVD-Grown
	Hierarchical Three-Dimensional MoS <sub>2</sub>
	Jeongin Song <sup>1,2</sup> , Se Min Hwang <sup>1,3</sup> Min Sup Choi <sup>3</sup> , Sang Woo Kang <sup>1,4</sup> , Taesung Kim <sup>2</sup> ,
	and Jihun Mun <sup>1</sup> <sup>1</sup> KRISS, <sup>2</sup> Sungkyunkwan University, <sup>3</sup> Chungnam National University, <sup>4</sup> University of
	Science and Technology
	Influence of Grain size on Amplified Spontaneous Emission in Metal Halide
	Perovskite
TK3-J-4 16:35-16:50	Hyeree Kim <sup>1</sup> , Seung-Je Woo <sup>2</sup> , Kyung Yeon Jang <sup>1</sup> , and Tae-Woo Lee <sup>1,3</sup>
	<sup>1</sup> Department of Material Science and Engineering, Seoul National University, <sup>2</sup> Cavendish
	Laboratory, University of Cambridge, UK, <sup>3</sup> Research Institute of Advanced Materials,
	Institute of Engineering Research, Soft Foundary, Interdisciplinary Program in
	Bioengineering, SN Display Co. Ltd, Seoul National University
	Blooting, on Bioplay Go. Eta, Goodi National Offiversity



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	Enhanced Gating Efficiency in Vertical Mixed Molecular Transistors with
TK3-J-5	Deep Orbital Level
16:50-17:05	Donguk Kim, Hyemin Lee , Minwoo Song, Jongwoo Nam, and Takhee Lee
	Department of Physics and Astronomy, Seoul National University
	Development of CMOS-Integrated TiO <sub>x</sub> Memristor Array for In-Memory
	Computing
TK3-J-6	Yeon Seo An <sup>1</sup> , Dowon Kim <sup>3</sup> , Young Ran Park <sup>1</sup> , Jung Sun Eo <sup>1</sup> , Mingyu Kim <sup>1</sup> , Donghyeok
17:05-17:20	Kim <sup>1</sup> , Hyeon Bin Kim <sup>1</sup> , Byunggeun Lee <sup>3</sup> , and Gunuk Wang <sup>1,2</sup>
	<sup>1</sup> KU-KIST Graduate School of Converging Science and Technology, <sup>2</sup> Department of
	Integrative Energy Engineering, Korea University, <sup>3</sup> GIST